AMENDMENTS TO THE CLAIMS

The following listing of claims will replace all prior versions and listing of claims in the application. For the Examiner's convenience a complete listing of all claims incorporating the amendments made herein is attached as Appendix A.

LISTING OF CLAIMS:

10:00

1. (Currently Amended) A process for the preparation of a compound of Formula I:

Formula I

wherein:

R1 and R2 are independently optionally substituted alkyl;

X is pyrazol-4-ylX is optionally substituted heteroarylene;

Y is a covalent bond or lower alkylene; and

Z is optionally substituted monocyclic aryl or optionally substituted monocyclic heteroaryl;

comprising;

cyclizing a compound of the formula (3):

$$\begin{array}{c|c}
R^1 & & H & X & Z \\
N & & NH_2 & & & \\
\hline
 & & & & & & \\
\end{array}$$
(3)

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PAGE 3/28 * RCVD AT 5/19/2006 12:55:31 PM [Eastern Daylight Time] * SVR:USPTO-EFXRF-2/7 * DNIS:2738300 * CSID:650 475 0359 * DURATION (mm-ss):05-24

wherein R¹, R², X, Y, and Z are as defined above.

- 2. (Original) The process of claim 1, wherein the compound of formula (3) is cyclized in an inert solvent in the presence of a base.
- 3. (Original) The process of claim 2, wherein the inext solvent is methanol and the base is aqueous sodium hydroxide solution.
- 4. (Currently Amended) The process of claim 3, wherein R¹ and R² are independently lower alkyl, X is pyrazol-4-yl, Y is methylene, and Z is optionally substituted phenyl.
- 5. (Original) The process of claim 4, wherein R¹ is n-propyl, R² is ethyl, and Z is 3-trifluoromethylphenyl.
- 6. (Previously Presented) The process of claim 1, wherein the compound of formula (3):

is prepared by a method comprising contacting a compound of the formula (2);

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with a compound of the formula Z-Y-X-CO₂H in the presence of a carbodiimide or with a compound of the formula Z-Y-X-C(O)Hal, where Hal is chloro or bromo.

- 7. (Previously Presented) The process of claim 6, wherein the compound of formula (3) is reacted with a compound of the formula Z-Y-X-CO₂H in methanol.
- 8. (Previously Presented) The process of claim 7, wherein the carbodiimide is 1-(3-dimethylaminopropyl)-3-ethylcarbodiimide.
- 9. (Previously Presented) The process of claim 6, wherein the compound of formula (3) is reacted with a compound of the formula Z-Y-X-C(O)Cl.
- 10. (Original) The process of claim 9, wherein the reaction is carried out in an inert solvent in the presence of a tertiary base.
- 11. (Original) The process of claim 10, wherein the inert solvent is acetonitrile and the tertiary base is triethylamine.
- 12. (Original) The process of claim 6, wherein R¹ and R² are independently lower alkyl, X is pyrazol-4-yl, Y is methylene, and Z is optionally substituted phenyl.
- 13. (Original) The process of claim 12, wherein R¹ is n-propyl, R² is ethyl, and Z is 3-trifluoromethylphenyl, namely 3-ethyl-1-propyl-8-{1-[(3-trifluoromethylphenyl)methyl]pyrazol-4-yl}-1,3,7-trihydropurine-2,6-dione.

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14. (Original) The process of claim1, wherein the compound of the formula:

is prepared by a method comprising contacting a compound of the formula;

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(16)

with a compound of the formula R¹L, in which L is a leaving group.

- 15. (Original) The process of claim 14, wherein R¹ is lower alkyl optionally substituted by cycloalkyl, and L is iodo.
- 16. (Original) The process of claim 15, wherein the reaction is carried out in the presence of a base in an inert solvent.
- 17. (Original) The process of claim 16, wherein the base is potassium carbonate and the inert solvent is N,N-dimethylformamide.
- 18. (Original) The process of claim 17, wherein R¹ and R² are independently lower alkyl, X is pyrazol-4-yl, Y is methylene, and Z is optionally substituted phenyl.

- 19. (Original) The process of claim 18, wherein R^1 is n-propyl, R^2 is ethyl, and Z is 3-trifluoromethylphenyl.
 - 20. (Original) The process of claim1, wherein the compound of the formula:

$$\begin{array}{c|c}
R^1 & & & \\
N & & & \\
R^2 & & & \\
\end{array}$$
(3)

is prepared by a method comprising contacting a compound of the formula;

with a compound of the formula R²L, in which L is a leaving group.

- 21. (Original) The process of claim 20, wherein R² is lower alkyl optionally substituted by cycloalkyl, and L is iodo.
- 22. (Original) The process of claim 21, wherein the reaction is carried out in the presence of a base in an inert solvent.
- 23. (Original) The process of claim 22, wherein the base is potassium carbonate and the inert solvent is N,N-dimethylformamide.

- 24. (Original) The process of claim 23, wherein R¹ and R² are independently lower alkyl, X is pyrazol-4-yl, Y is methylene, and Z is optionally substituted phenyl.
- 25. (Original) The process of claim 24, wherein R¹ is n-propyl, R² is ethyl, and Z is 3-trifluoromethylphenyl.
- 26. (Previously Presented) The process of claim 14, wherein the compound of the formula:

(16)

is prepared by a method comprising contacting a compound of the formula:

with a compound of the formula Z-Y-X-CO₂H in the presence of a carbodiimide or with a compound of the formula Z-Y-X-C(O)Hal, where Hal is chloro or bromo.

- 27. (Previously Presented) The process of claim 26, wherein the compound of formula (15) is reacted with a compound of the formula Z-Y-X-CO₂H in methanol.
- 28. (Previously Presented) The process of claim 27, wherein the carbodismide is 1-(3-dimethylaminopropyl)-3-ethylcarbodismide.

- 29. (Previously Presented) The process of claim 26, wherein the compound of formula (15) is reacted with a compound of the formula Z-Y-X-C(O)Cl.
- 30. (Original) The process of claim 29, wherein the reaction is carried out in an inert solvent in the presence of a tertiary base.
- 31. (Original) The process of claim 30, wherein the inert solvent is acetonitrile and the tertiary base is triethylamine.
- 32. (Original) The process of claim 31, wherein R^1 and R^2 are independently lower alkyl, X is pyrazol-4-yl, Y is methylene, and Z is optionally substituted phenyl.
- 33. (Original) The process of claim 32, wherein R^1 is n-propyl, R^2 is ethyl, and Z is 3-trifluoromethylphenyl.
- 34. (Previously Presented) The process of claim 19, wherein the compound of the formula:

$$R_1$$
 N_{1} N_{1} N_{2} N_{1}

(13)

is prepared by a method comprising contacting a compound of the formula:

$$NH_2$$
 NH_2
 NH_2
 NH_2
 NH_2

with a compound of the formula Z-Y-X-CO₂H in the presence of a carbodiimide or a compound of the formula Z-Y-X-C(O)Hal, where Hal is chloro or bromo.

- 35. (Previously Presented) The process of claim 34, wherein the compound of formula (12) is reacted with a compound of the formula Z-Y-X-CO₂H in methanol.
- 36. (Previously Presented) The process of claim 35, wherein the carbodiimide is 1-(3-dimethylaminopropyl)-3-ethylcarbodiimide.
- 37. (Previously Presented) The process of claim 34, wherein the compound of formula (12) is reacted with a compound of the formula Z-Y-X-C(O)Cl.
- 38. (Original) The process of claim 37, wherein the reaction is carried out in an inert solvent in the presence of a tertiary base.
- 39. (Original) The process of claim 38, wherein the inert solvent is acetonitrile and the tertiary base is triethylamine.
- 40. (Original) The process of claim 39, wherein R¹ and R² are independently lower alkyl, X is pyrazol-4-yl, Y is methylene, and Z is optionally substituted phenyl.
- 41. (Original) The process of claim 40, wherein R^1 is n-propyl, R^2 is ethyl, and Z is 3-trifluoromethylphenyl.

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42. (Original) The process of claim 34, wherein the compound of the formula:

is prepared by a method comprising the steps of:

a) contacting a compound of the formula:

with hexamethyldisilazane in the presence of an acid catalyst;

- b) contacting the product thus formed with R¹L, where L is a leaving group, followed by;
 - c) contacting the product thus formed:

with a mixture of sodium nitrite in acetic acid/water; and

d) contacting the product thus formed:

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with a mixture of aqueous ammonia and sodium dithionite.

- 43. (Original) The process of claim 42, wherein in step a) R¹ is lower alkyl, L is iodo, and the acid catalyst is ammonium sulfate.
 - 44. (Original) The process of claim 26, wherein the compound of the formula:

is prepared by a method comprising the steps of:

a) contacting a compound of the formula:

with ethyl cyanoacetate in the presence of a base in a protic solvent;

b) contacting the product thus formed:

with a mixture of sodium nitrite in acetic acid/water; and

c) contacting the product thus formed:

with a mixture of aqueous ammonia and sodium dithionite.

- 45. (Original) The process of claim 44, wherein the base is sodium ethoxide and the protic solvent is ethanol.
 - 46. (Original) The process of claim 6, wherein the compound of formula:

is prepared by a method comprising the steps of:

a) contacting a compound of the formula:

with ethyl cyanoacetate in the presence of a base in a protic solvent;

b) contacting the product thus formed:

with the dimethylacetal of N,N-dimethylformamide;

c) contacting the product thus formed:

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with a compound of formula R¹L, in which L is a leaving group;

d) contacting the product thus formed:

with aqueous ammonia;

e) contacting the product thus formed:

with a mixture of sodium nitrite in acetic acid/water, and

f) contacting the product thus formed:

with a mixture of aqueous ammonia and sodium dithionite.

47. (Original) The process of claim 46, wherein the base is sodium ethoxide and the protic solvent is ethanol.

Claims 48-55 Cancelled

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